

Article

# PZT/PZT and PZT/BiT Composite Piezo-Sensors in Aerospace SHM Applications: Photochemical Metal Organic+Infiltration Deposition and Characterization

Hamidreza Hoshyarmanesh<sup>1</sup>, Nafiseh Ebrahimi<sup>2</sup>, Amir Jafari<sup>2</sup>, Parisa Hoshyarmanesh<sup>3</sup>,  
Hyung-Ho Park<sup>4\*</sup>

<sup>1</sup> Project neuroArm, Department of Clinical Neurosciences and Hotchkiss Brain Institute, Health Research Innovation Center, Cumming School of Medicine, University of Calgary, Alberta T2N 4Z6, Canada;

<sup>2</sup> Department of Mechanical Engineering, University of Texas at San Antonio, One UTSA Circle San Antonio, TX 78249, USA; [nafiseh.ebrahimi@utsa.edu](mailto:nafiseh.ebrahimi@utsa.edu) and [amir.jafari@utsa.edu](mailto:amir.jafari@utsa.edu)

<sup>3</sup> Department of Organic Chemistry, University of Isfahan, Isfahan, Iran; [p.hoshyarmanesh@gmail.com](mailto:p.hoshyarmanesh@gmail.com)

<sup>4</sup> Department of Materials Science and Engineering, Yonsei University, Seoul 03722, South Korea; [hhpark@yonsei.ac.kr](mailto:hhpark@yonsei.ac.kr)

\* Correspondence: [hhpark@yonsei.ac.kr](mailto:hhpark@yonsei.ac.kr); Tel.: (02) 2123-2853

**Abstract:** The composition of fine-ground lead zirconate-titanate powder  $\text{Pb}(\text{Zr}_{0.52}\text{Ti}_{0.48})\text{O}_3$ , suspended in PZT and bismuth titanate (BiT) solutions, is deposited on the curved surface of IN718 and IN738 nickel-based super alloy substrates up to 100  $\mu\text{m}$  thickness. Photochemical metal organic and infiltration techniques are implemented to produce smooth, semi-dense, and crack-free random orientated thick piezoelectric films as piezo-sensors, free of any dopants or thickening polymers. Every single layer of the deposited films is heated at 200°C with 10 wt.% excess  $\text{PbO}$ , irradiated by UV lamp (365 nm, 6 watt) for 10 minutes, pyrolyzed at 400°C, and subsequently annealed at 700°C for one hour. This process is repeated successively until reaching the desired thickness. Au and Pt thin films are deposited as the bottom and top electrodes using evaporation and sputtering methods, respectively. PZT/PZT and PZT/BiT composite films are then characterized and compared to similar PZT and BiT thick films deposited on the similar substrates. The effect of composition and deposition process is also investigated on the crystalline phase development and microstructure morphology as well as dielectric, ferroelectric and piezoelectric properties of piezo-films. The maximum remnant polarization of  $P_r=22.37\pm0.01$ ,  $30.01\pm0.01$   $\mu\text{C}/\text{cm}^2$ , the permittivity of  $\epsilon_r=298\pm3$ ,  $566\pm5$  and piezoelectric charge coefficient of  $d_{33}=126$ ,  $148$  m/V were measured versus the minimum coercive field of  $E_c=50$ ,  $20$  kV/cm for the PZT/PZT and PZT/BiT thick films, respectively. The thick film piezo-sensors are developed to be potentially used at frequency bandwidth of 1–5 MHz for rotary structural health monitoring and also in other industrial or medical applications as a transceiver.

**Keywords:** Composite; Piezoelectric sensor; Thick film; Sol-gel PMOD deposition; Infiltration; PZT/PZT; PZT/BiT; Characterization; Structural health monitoring; Aerospace structure

## 1. Introduction

Piezoelectric thin films have been used vastly as sensors, accelerometers, micro-motors, and many other low-force electromechanical (E/M) applications [1]. However, high-frequency transducers for structural health monitoring and vibration control systems usually require higher thickness to convey appropriately E/M stimulation loads. In such cases, there is a need for thick piezoelectric films with more than 10 microns thicknesses [2–8]. Therefore, thin films cannot be applicable this way. Ferroelectric thick films for applications like high-frequency sonars [9] micro-electromechanical devices [10], elastic surface wave generators [11], hydrophones [12], and sensors [13] have been of great interest in the last decade; since such films have both characteristics of the

bulk material and thin-layer films at the same time [14]. With this regard, the process of thick films has become a highly interested research area, recently. Conventional methods currently being used for the production of semi-thick or thick films, including pulsed laser deposition [15, 16], print screen [17], sol-gel spray [18], and hybrid sol-gel [13, 19, 20], are not effective nor economic to produce dense films in a rather short time with minimal waste of material, particularly for deposition on substrates with irregular shapes. Using sol-gel technique, by itself, to deposit thick films entails a significant number of repetitions to get the desired thickness, layer-after-layer. This leads to frequent temperature fluctuations that might increase the possibility of cracking due to film contraction or thermal fatigue stress at each layer [21].

Among the aforementioned methods, the hybrid sol-gel has been taken more into consideration for thick films due to low preparation time, cost and appropriate controllability on the precursors stoichiometry [19], which may not be so easy to achieve through the other methods. Other methods such as electromagnetic sputtering with radio frequency waves (RF) are also utilized in the production of piezoelectric films [22]. The produced films with RF sputtering have slight thicknesses in order of nanometer, which cannot meet the requirements of monitoring applications in high-frequency transducers. The implementation of RF takes usually 24 hours for one-micron thickness. This issue will increase the deposition cost significantly. In case that the evaporation method is applied rather than RF sputtering, the precise control of the stoichiometry of the composition is so crucial. Particularly, for PZT the lead is an element, which evaporates faster than the remaining materials; so the control of lead amount in the compound is difficult using evaporation technique. If the deposition method is replaced by DC sputtering, the coating will not be easy due to the non-conductivity of the target material, and the sedimentation rate may be too slow, thus the resultant piezo-film may not be qualified for monitoring applications as sensor or actuator. Reactive Magnetron Pulsed DC Sputtering (RMPDS) or RF-Bias might be a good solution; nonetheless, it is not yet an appropriate system capable of coating over the curved surface of large industrial components. The sol-gel is an appropriate and quality method to prepare thick ceramic films with the thickness of more than one micron. The fabrication of thick composite films with this method has two main steps: <sup>1)</sup> sol-gel matrix selection, and <sup>2)</sup> dispersion of the piezoelectric powder within the sol-gel matrix.

During the second step, preparation of a homogenous suspended mixture is so important to reduce the possibility of the agglomeration [19, 23]. Attention should be given to the inappropriate mixing of the powder within the piezoelectric solution and long staying of the mixture before deposition, which could possibly yield to <sup>1)</sup> forming the surface layers, <sup>2)</sup> strengthening the surface tension forces, <sup>3)</sup> sedimentation of the suspended powder, and therefore, <sup>4)</sup> agglomeration after the coating process. To avoid the agglomeration before and during the preparation process of thick films, researchers usually apply high molecular-weight solvents, such as acetic acid (60.05 g/mol), hexane (86.17 g/mol), methoxyethanol (76.09 g/mol), and  $\alpha$ -terpined (154.25 g/mol) [1], binders including polyvinylpyrrolidone, plasticizers such as polyethylene glycol and organic diffusers such as butoxyethoxy-ethyl acetate. Although the smaller particles seem to result in less localized powder accumulation in the sol-gel matrix and improve the density of the resultant film, it is not entirely true. The reduction of the powder size leads to an increase in the effective particle surface, which raises the surface tension. The surface tension remarkably contributes in the powder agglomeration. Therefore, the conventional solid-state oxide method (dry method) with particle sizes larger than 2  $\mu\text{m}$  for the production of PZT powder is preferred vs coprecipitation process (wet method), which normally causes particle smaller than 2  $\mu\text{m}$  in diameter. Dispersion of the piezoelectric powder in the precursor solution using an ultrasonic vibrator is an applicable method to avoid agglomeration and consequently reduce the porosity of thick films [19].

Barrow et al. [24] fabricated thick piezoelectric films without cracks. They pertain the crack-free feature of the proposed films to the following factors: <sup>1)</sup> a considerable powder to precursor solution ratio, which reduces the shrinkage after annealing, and <sup>2)</sup> strong bound between sol-gel and PZT particles. Wu et. al [25] declared that the presence of 1% wt PZT powder in the hybrid sol-gel has more advantages, e.g., a 50-degree reduction in the temperature of the perovskite phase formation

and significant improvement in the dielectric and ferroelectric characteristics. Nevertheless, many researchers believe that the intermixture of piezoelectric powder with sol-gel matrix causes non-homogeneous crystallization of the perovskite phase and the formation of a random-oriented structure.

In this research, PZT/PZT and PZT/BiT composite films are deposited on the curve surface of IN718 and IN738 superalloy substrates using photochemical metal organic deposition including UV irradiation and infiltration technique. The details of the deposition process will be presented in section 2. The experimental set up will be introduced in section 3. Section 4 involves the subsequent results of characterization regarding the microstructural, morphological, dielectric, ferroelectric and piezoelectric properties of the proposed thick films. Section 5 is assigned to the conclusions.

2. Materials and Methods

A hybrid sol-gel technique, PMOD and Infiltration, was applied in this research to deposit piezotransducers in the form of composite thick films on the curved surface of industrial components. Taking advantage of this hybrid method, PZT/PZT, and PZT/BiT composites are prepared with the introduction of a certain mass percentage of PZT-5A powder, with 2–5 μm particle size, in PZT and BiT precursor solutions, respectively. Piezoelectric characteristics of PZT-5A is presented in Table 1 [26–28]. The dielectric constant  $\epsilon_r$  in the tables is correlated with free piezoelectric samples. The stacked wafers bonded to a substrate mostly have  $\epsilon_r < 1000$  [29].

Table 1. Physical, dielectric and piezoelectric properties of PZT-5A free samples [30]

	Thermal expansion coefficient (CTE) °C	Dielectric constant $\epsilon_r$ @1kHz	Curie temperature ( $T_c$ ) °C	Density (g/cm <sup>3</sup> )	Dielectric loss $\tan\delta$	Piezoelectric coefficient $d_{33}$ (pm/V)	Piezoelectric coefficient $d_{31}$ (pm/V)
PZT-5A	3.6e-6	1600	365	7.7	0.02	350	-190
Zr:Ti=52:48	Longitudinal E/M coupling factor $k_{33}$	Transverse E/M coupling factor $k_{31}$	Effective E/M coupling factor $k_{eff}$	Remnant polarization $P_r$ (μm/cm <sup>2</sup> )	Coercive field $E_c$ (kV/cm)	Saturated polarization $P_{sat}$ (μm/cm <sup>2</sup> )	
	0.53	0.4	0.5	23	27.7	11.8	

PZT precursor solution is prepared using lead 2-ethylhexanoate, zirconium 2-ethyl hexanoate and Ti-isopropoxide in molar ratio Pb:Zr:Ti = 1.1:0.52:0.48 as the precursors. The applied mixing order and synthesis process are the same as proposed in [4, 6, 7]. Then, hexane solvent is added to the solution in order to dilute it to 0.4 M. To make the BiT precursor solution of molar ratio Bi:Ti = 4.4:3, bismuth 2-ethylhexanoate is dissolved in hexane as the solvent. Then titanium isopropoxide is added and the mixture is stirred on the vibrator for 4 hours, as described in [4, 6, 7]. Before starting off the coating process, the substrates are washed and shadow masked in square shapes of 10×10mm and 15×15mm using temperature-resistant Kapton tape. Two layers of the 600-nm gold bottom electrode are deposited on the masked surface using a thermal evaporation system. Coating of composite films is initiated by the injection of the suspended mixture of PZT/PZT and PZT/BiT on the surface of Si and Pt/Si flat wafers.

Each deposited layer then goes through drying at 200 °C on a hot plate for 2 minutes, UV irradiation inside an exposure chamber under a 365 nm UV lamp for 10 minutes, and pyrolyzing at 400 °C for 2 minutes, successively. These procedures are repeated for the subsequent layers to reach the desired thickness. The rotational speed of the spin coater is adjusted at 1500 rpm, much less than that is usually used for thin and thick films. Higher speeds cause the piezoelectric powder to sprinkle out entirely and do not make a uniform layer. The UV irradiation allows for a better rupture and ejection of the hydrocarbon chains of the ligands from the precursor films. A scheme for the consecutive steps of the hybrid sol-gel process is illustrated in Figure 1.

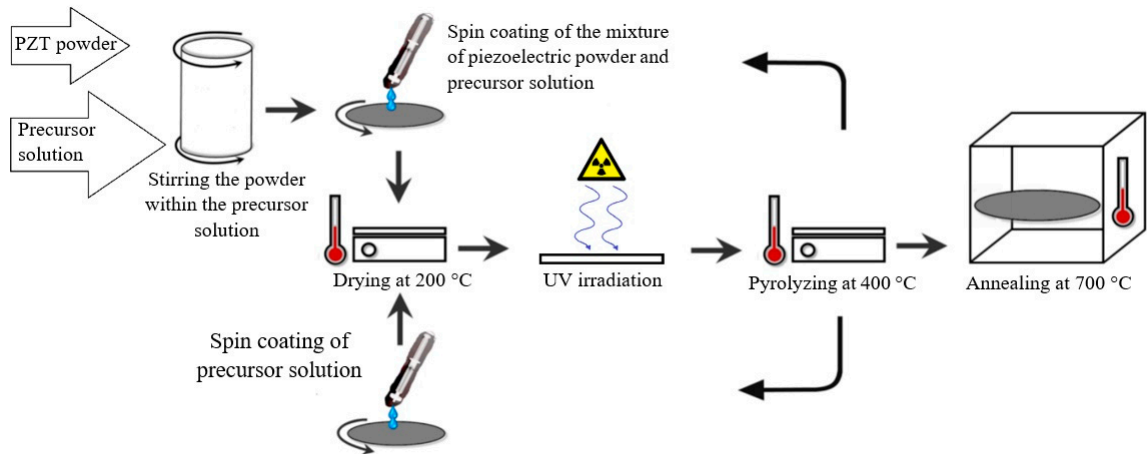


Figure 1. The consecutive steps of hybrid sol-gel deposition including the mixture of piezoelectric powder and precursor solution, injection, drying, UV irradiation, pyrolyzing, and annealing.

Figure 2 shows a sample of composite PZT/PZT thick film deposited on the surface of a silicon wafer using photochemical sol-gel technique. The results revealed that sol-gel deposition of the thick composite films lacks enough bounding to the substrate, durability, strength, and resistance to crack.

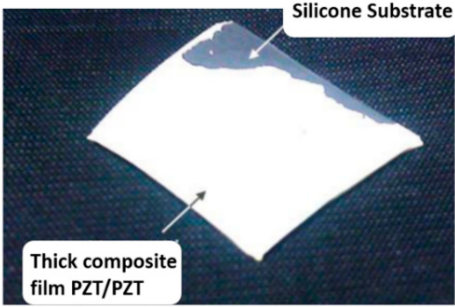


Figure 2. Five-layer PZT/PZT composite film derived from sol-gel method over the silicon wafer.

To avoid the aforementioned shortcoming regarding the deposition of thick piezoelectric films using the sol-gel technique, the infiltration method is implemented. To apply the infiltration technique, the injection was modified such that the PZT or BiT precursor solution is initially dropped down as the first layer followed by the injection of the mixture of PZT/PZT or PZT/BiT suspension upon the surface of Si and Pt/Si flat wafers. These two steps, i.e., deposition of the precursor solution as the odd layers and powder suspension deposition as the even layers, are cyclically repeated for the subsequent layers.

The surface morphology and microstructure of the resultant films were recorded by a scanning electron microscope (SEM) model FESEM JEOL JSM-600F (JEOL, USA). The surface profile and the thickness of the films were measured by Alpha-Step IQ (KLA-Tencor, USA). The surface roughness of the samples was investigated using Perthometer M2 (Mahr, Germany). The grain size, phase, and crystalline microstructure of the films were also measured and recorded using Rigaku D/MAX-2000 X-ray diffractometer (Rigaku, Japan) with the diffraction range of 20–80° at 40 kV, 30 A, 4 deg./min and 0.02° angular resolution.

### 3. Design and Experiments

To coat the thick layers of piezoelectric films on the curved surface of superalloy blades IN718 and IN738 as the main substrates in this research, the blades are first washed and masked similar to what explained before. We washed the blades using acetone and methanol and put them in the ultrasonic bath of ethanol and deionized water for a longer time compared to the small Si and Pt wafers. Then, a layer of PZT or BiT precursor solution is deposited on the top surface of the blades using a 0.3-micron filter. The injection is carried out over the same area already coated with a gold



bottom electrode. After injection of each layer, the blades are placed in the spin coater to disperse uniformly the localized drop over the whole masked area at 1500 rpm for 30 seconds. The procedures of UV irradiation, pyrolyzing and annealing is thoroughly performed for the first layer to the end.

After the suspended mixture of PZT/PZT or PZT/BiT composite is dropped down over the first layer and the composite layer is taken into the post-injection procedures, similar to the first one. To reach the composite structure of  $n[C+kS]$  in this fashion, the films are made  $n$  mixed layers, each of which composed of one composite PZT/PZT or PZT/BiT (C) layer in addition to  $k$  layers of the PZT or BiT precursor solutions (S). In other words, along with each layer of PZT/PZT or PZT/BiT,  $k$  layers of a sol-gel solution is injected. This approach is taken into action in order to first, eliminate the graded structure which causes the reduction of dielectric, ferroelectric and piezoelectric characteristics; second, homogenization of the layer structures and diminution in the porosity of the thick composite films. In this research,  $k=2$  opted.

The rotational speed of the spin coater is proportionally adjusted to the average PZT particle size and the viscosity of the sol-gel matrix. The larger the average particles size and the more viscose the solution, the rotational speed decreases toward 1000 to 1500 rpm. By reducing the grain size, the appropriate speeds in the range of 1500 to 4000 can be selected proportional to the final thickness. The 20–30 seconds for the spinning time works appropriately; as below the 20 seconds the piezoelectric powder is not going to be scattered, entirely and evenly on the substrate, and the timing beyond the 30 seconds does not help out, any longer. The resultant film after pyrolysis has a proper macroscopic quality having no visual cracks. It also has an even thickness accompanied by an almost homogeneous structure in white color.

The first layer, which is the interface between the piezo-film and the substrate, and the last layer, the top surface of the film, is coated with PZT or BiT sol-gel solution. The former is aimed to strengthen the connection between the composite piezo-ceramic film and the substrate; the latter is performed to reduce the surface roughness and minimize the wear percentage as much as possible. As the number of layers increases, the previous composite layers are enriched with a sol-gel solution, which fills the cavities of the underlying layers and reduces the porosity. Cruz [31] has already recognized the saturation capacity of this repetition as up to four times for sol-gel penetration. According to him, iteration does not affect the porosity of the underlying layers after conducting four times of infiltration procedure.

Ball milling of the PZT powder for 60 hours and using the ultrasonic vibrator for extracting grain size of 2 microns help avoid the additional adhesives, plasticizers, and solvents. Hence, besides reducing the impurities, the length of time spent on drying and pyrolyzing of thick piezo-ceramic films — that sometimes exceeds 24 hours — is considerably diminished [1]. Refraining from solvents with high molecular masses leads to a reduction of the formation of large porosities during the evaporation of volatile substances.

Thermal treatment and post-processing of thick films after coating in the hybrid sol-gel method do not differ much from the method implemented for thin films, mentioned in [32]. One major difference is the cooling rate of the samples after drying, pyrolyzing, and annealing. The cooling rate of 5 °C/min showed promising results to eliminate surface cracking. Other researchers have implemented a drying temperature region of 100–300 °C for one to several minutes, depending on the type of solvent and also the organic compounds in the sol-gel matrix. Moreover, the pyrolyzing process — also known as pre-annealing or calcination — has been carried out in the temperature range of 300–500 °C for one to several minutes, too. Due to the curvature of the superalloy blades and the lack of direct contact with the hot plate, uniform distribution of thermal energy over the whole surface of the blade was not feasible. Thus, during the spinning, drying, and pyrolyzing processes, aluminum foil pads with the same curvature of the blades were located underneath aimed at uniform distribution of thermal energy all over the piezoelectric films. The annealing process was accomplished for the formation of the perovskite crystal phase in piezo-ceramic samples. The annealing temperature for the PZT/PZT and PZT/BiT films was adjusted at 700 °C and the annealing time was confined to 60 minutes similar to what was reported for thin films [22, 31, 33]. Considering the fact that spin coating is a very common method for the flat and small substrates, spin coating of

composite piezo-ceramic films on a curved substrate would be challenging. The smaller Ruston-TA blade, made of IN738, with 60 mm length, 30 mm width, and 52 g mass was coated first. The bigger challenge was for coating the JT8D blades, made of IN718, with 128 mm length, 46 mm width, and 212 g mass. The spin coating on this blade looked practically infeasible. For this reason, we considered an injection method for this type of substrates and the spinning step was eliminated.

Six JT8D, hereafter called L<sub>1</sub>–L<sub>6</sub>, and five Ruston-TA, S<sub>1</sub>–S<sub>5</sub>, blades were considered for the deposition process. Figure 3a depicts a couple of 10×10 mm and 15×15 mm semi-square PZT/BiT deposited films with 100 μm thickness on the blade L<sub>1</sub> at positions A (near the root) and B (center), respectively. Figure 3b shows two 15×15 mm PZT/ PZT films of 30 μm thickness at positions A and C (near the shroud) on the blade S<sub>5</sub> applying hybrid sol-gel deposition method. A small part of each film remained uncoated to provide access to the bottom gold electrode for micro-wiring and post electrical characterization of the piezo-sensors. In the end, two layers of the 600-nm thick gold electrode were coated on top of each film, deposited on the blades of type L, using the evaporation method. Five layers of platinum with the final thickness of 100 nm were also deposited over the composite films, laid on the blades of type S, using a DC sputtering method.

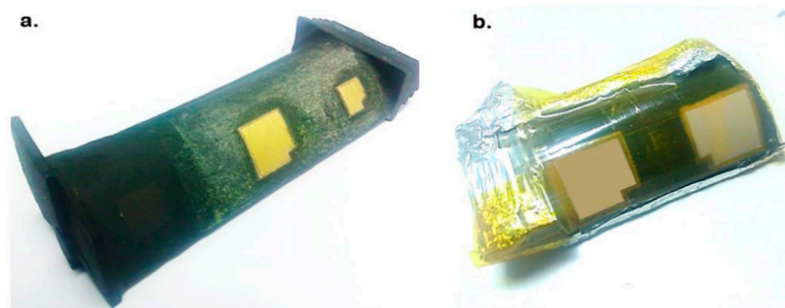


Figure 3. Deposition of the composite piezoelectric films on the curved surface of superalloy blades using the hybrid sol-gel-infiltration method, a) JT8D L<sub>1</sub> and b) Ruston-TA S<sub>5</sub>.

After coating the top electrode, the samples underwent a secondary annealing in the tube furnace for 30 minutes at 600 °C in order to make a proper connection between the electrodes and the piezoelectric films. The thickness of the top electrode has an optimal value in terms of maximum electrical conductivity and minimum impact on the electromechanical properties of the piezoelectric films. It is worth noting that the ohmic behavior of the films decreases as their planar dimensions raise [34]. In thicker electrodes, the resistance is less affected by the electrode width. However, the growth of electrode thickness has a negative impact on the mechanical behavior of the composite piezo-sensors and piezo-actuators. The 600 nm seems an appropriate value regarding the surfaces roughness of the films and the height of asperities.

## 4. Results and Discussions

### 4.1. Visual Microscopic Inspection

The effect of intermittent injection of sol-gel solution among the composite layers on the structure of the thick PZT/PZT and PZT/BiT films is first studied by analyzing the optical microscopic images presented in Figure 4. The figure depicts that the penetration of sol-gel solution has been very effective in the fabrication of a crack-free and smooth surface, reducing the porosity and strengthening the cohesion of the films compared to the samples for which infiltration had not been used. The images were captured from the film boundaries, where the agglomeration, cracks, voids, pores, and thickness non-uniformity are more likely compared to the central areas.

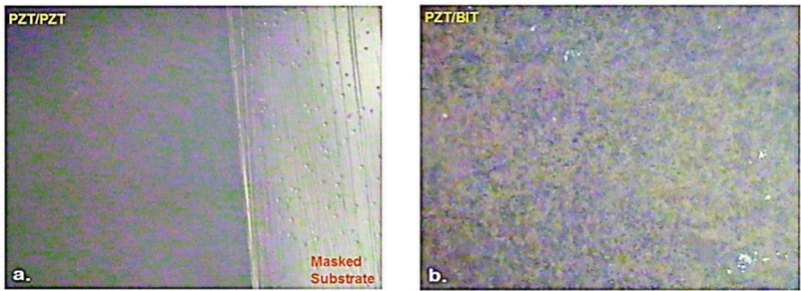


Figure 4. Optical microscopic images, composite films of a) PZT/PZT on S<sub>5</sub> and b) PZT/BiT on L<sub>5</sub>.

4.2 Surface Morphology

The mean value for the micro-hardness of the samples, out of three iterations for each sample, was measured via Vickers Indentation method and shown in Table 2. Since such films are supposed to be utilized actively in real-time structural health monitoring of rotary structures, the rotational speed of the blades causes abrasive wear and erosion especially in the field applications that might result in deterioration of top electrodes and piezoelectric films. Using the infiltration method is not only able to control of surface roughness of the composite films, but also to enhance the density and surface hardness of piezoelectric films to a great extent by filling the porosity percentage out. As inferred from Table 2, the film density affects the micro-hardness of piezoelectric films, significantly. By reduction of the porosity, micro-hardness will show a sensible rise. PZT is structurally harder than BiT; previous authors reported the Vickers hardness of reinforced BiT with zirconium and sodium elements as 3.2–5.4 GPa [35]. It is expected that the additive-free composite films consisting of BiT ingredients would have rather less hardness. In addition, the hardness of additive-free samples of PZT has been reported as 3.4 GPa with 95% density under a load of 500 g [36, 37].

Table 2. Micro-hardness values for piezoelectric composite films under 200gr load for 30 seconds				
Composite film	PZT/PZT	PZT/BiT	PZT	BiT
28% Porosity PZT/PZT no infiltration HV(MPa)	16% Porosity 30 μm, 5[C+2S] HV(MPa)	16% Porosity 50 μm, 5[C+2S] HV(MPa)	11% Porosity 15 μm (30-layer) HV(MPa)	9% Porosity 33 μm (30-layer) HV(MPa)
1480	3236	2942	3531	2844

The average roughness ( $R_a$ ) of composite thick films was also measured as represented in Table 3.  $R_a$  is a function of the grain size, the film thickness, and the number of sol-gel infiltration steps. It grows proportionally with the increase in the number of layers and also the film thickness. The thick films mostly have higher  $R_a$  due to encompassing larger particles compared to thin films. The smaller the  $R_a$ , the narrower and sharper peaks in the X-ray diffraction patterns could be observed, addressed in [1]. The sol-gel infiltration shows a great contribution to the improvement of the surface roughness, electrode connection and the precision of the profilometry.

Table 3. Mean values of the average roughness ( $R_a$ ) for the piezoelectric thick films (μm)						
BiT (~100 nm/layer)			Composite film PZT/PZT (no infiltration)	PZT/PZT 5[C+2S]	PZT/BiT 5[C+2S]	PZT (1-layer)
1-layer	5-layer	10-layer	50 μm	30 μm	50 μm	0.5 μm
0.008	0.015	0.012	7.65	1.757	1.276	0.007

Figure 5 shows the SEM images captured from the thick composite films of PZT/PZT and PZT/BiT of type 5[C+2S] with the thickness of 30 and 50 microns, respectively. The images illustrate the uniform distribution of PZT powder in the sol-gel matrix and a smooth surface on the top layer. Increasing the concentration of the precursor solution to above 0.4 M boosts the risk of trapped bubble formation in the piezoelectric film. Thereupon, the final concentration of the mixture was considered as 0.4 M. Similar results regarding the concentration were already reported by Dorey et al. [38].

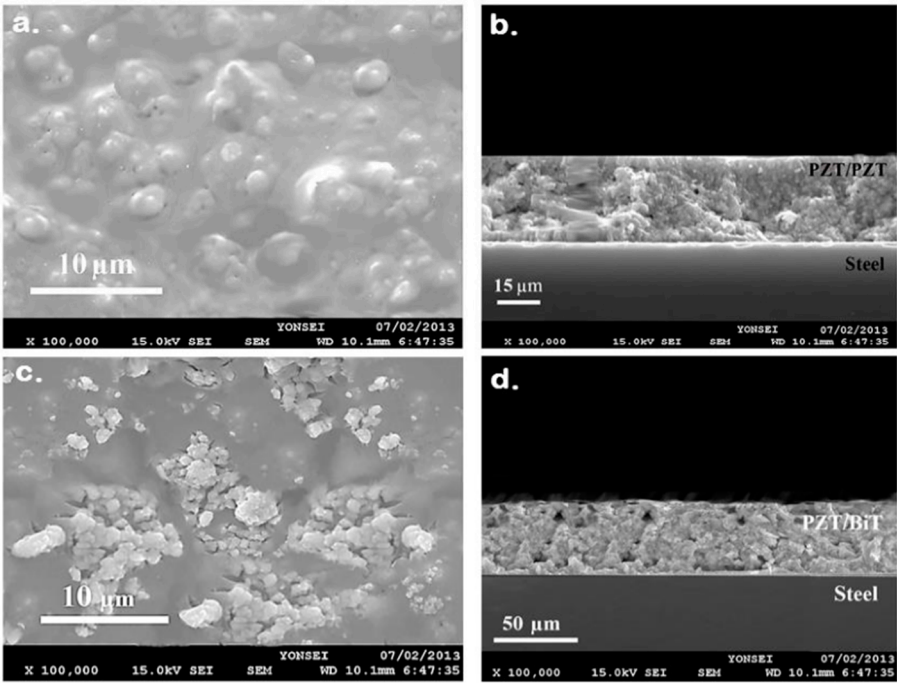


Figure 5. SEM images captured from hybrid thick films of type 5[C+2S] a,b) PZT/PZT of 30  $\mu\text{m}$  thickness, and c,d) PZT/BiT of 50  $\mu\text{m}$  thickness.

#### 4.3 Crystalline Structure

The XRD patterns obtained from multilayer PZT/PZT and PZT/BiT composite films are presented in Figure 6. The crystallographic plane (110) related to piezoelectric powder PZT-5A is apparent in the texture of the sol-gel. The orientation of (111) also corresponds to the sol-gel matrix.

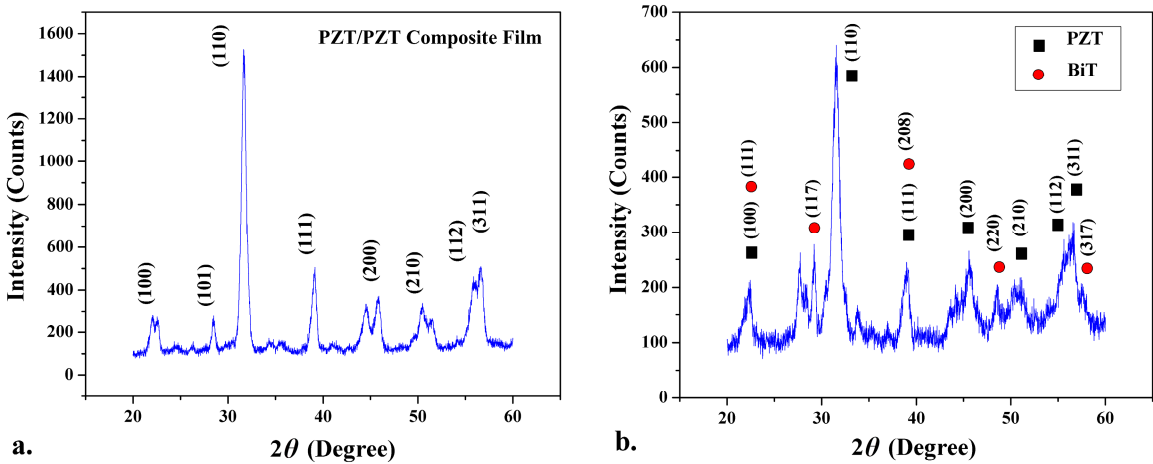


Figure 6. XRD patterns for a) PZT/PZT and b) PZT/BiT thick composite films.

#### 4.4 C-V Hysteresis Loop

The capacitance-voltage (C-V) hysteresis loop of several composite samples was calculated by means of the famous Sawyer-Tower method and applying  $\pm 330$  VDC at 100 kHz at the ambient temperature. Figure 7 demonstrates the results obtained from the 15 $\times$ 15 mm PZT/BiT, L<sub>1</sub>-B sample (at the center of the blade L<sub>1</sub>). The diagram shows a butterfly pattern with two peaks.



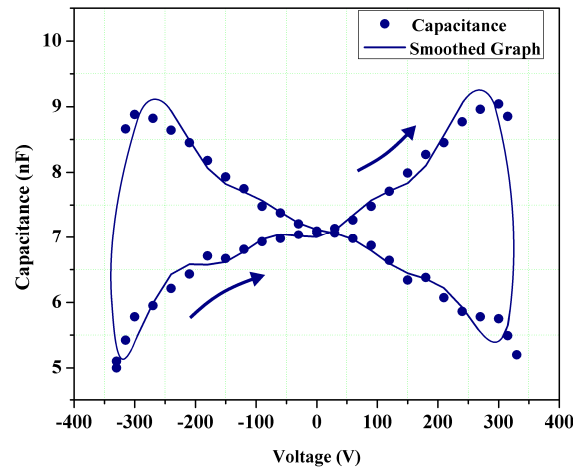


Figure 7. C–V hysteresis loop of L<sub>1</sub>-B thick film sample according to the Sawyer-Tower method.

4.5 Curie Temperature ( $T_c$ )

A number of experiments were carried out to determine the Capacitance-Temperature (C–T) behavior and, therefore, Curie temperature ( $T_c$ ) of the thick piezoelectric films using a hot plate and the Keithley 590 C–V Analyzer in the temperature range of 20–420 °C. Through the tests, the dielectric constant of the samples ( $\epsilon_r$ ) at various temperatures were obtained and its maximum value was recorded. At the Curie temperature, the  $\epsilon_r$  will be reaching to its maximum. The results expressed the Curie temperature of PZT/PZT samples nearly equal to 300–320 °C, and that of PZT/BiT samples around 370–380 °C. Figures 8 and 9 illustrate the C–T diagrams associated with different samples.

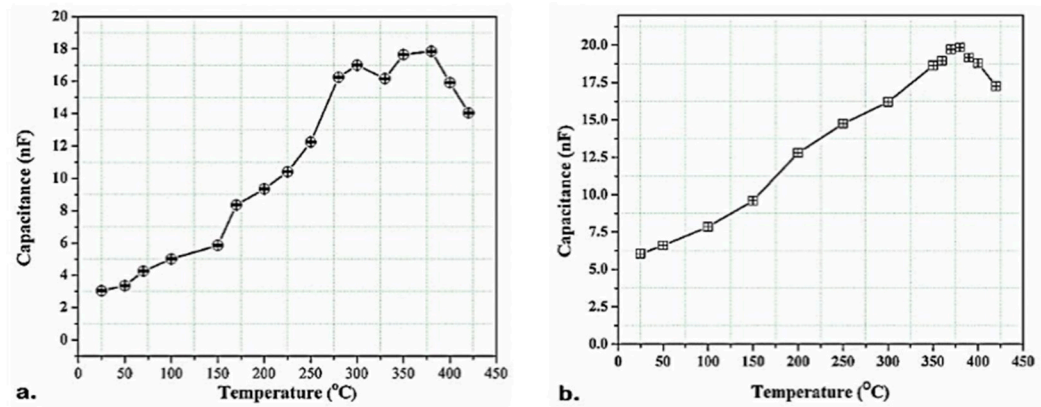


Figure 8. The C–T variations for the PZT/BiT films at 25–420 °C, a) L<sub>1</sub>-A and b) L<sub>1</sub>-B.

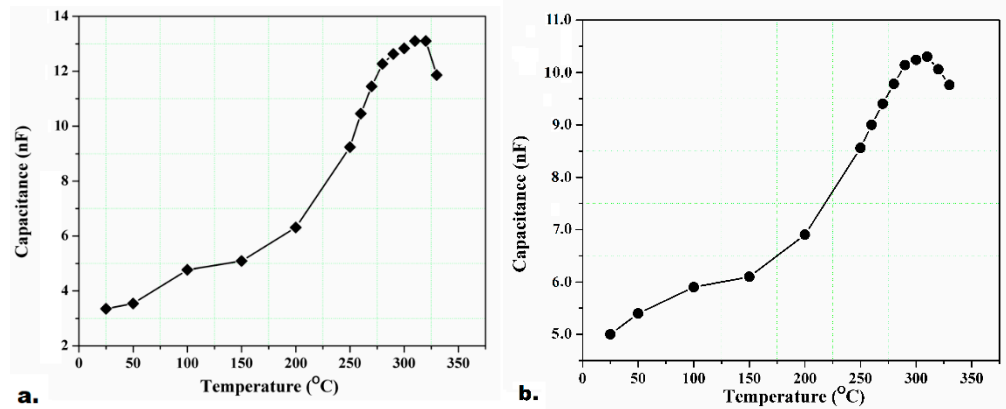


Figure 9. The C–T variations for the PZT/PZT films at 25–330 °C, a) L<sub>3</sub>-A and b) L<sub>3</sub>-B.

#### 4.6 Dielectric Permittivity ( $\epsilon_r$ )

According to the acquired results shown in Figure 10, there is a rise in dielectric permittivity ( $\epsilon_r$ ) as the number of layers and the infiltration steps increase; nevertheless, the dielectric loss ( $\tan \delta$ ) remains almost constant. It might happen due to a mitigation in material porosity and improvement in the bounding of piezoelectric powder particles with the sol-gel matrix. Concerning the dielectric permittivity of the samples, porosity acts like series or parallel capacitors in conjunction with the adjacent dense piezoelectric columns. As the volumetric ratio of porous cavities (filled with air) to the piezoelectric film grows up, the tendency of the air dielectric permittivity to be placed in serial, versus parallel, with that of the composite film increases. In other words, the volume of porous cavities adversely affects the relative dielectric constant.

The dimension, number of layers and porosity have a significant impact on relative dielectric constant. For two thick piezo-films with similar dimensions, e.g., L<sub>5</sub>-A and L<sub>5</sub>-B, the dielectric permittivity is almost identical. The dielectric permittivity of PZT/PZT films is less than that of PZT/BiT ones. The difference comes from the better penetration of BiT sol-gel solution among the composite layers which helps consequently of obtaining less porosity. BiT solution also has higher viscosity compared to PZT solution which makes it easier to reach higher thickness.

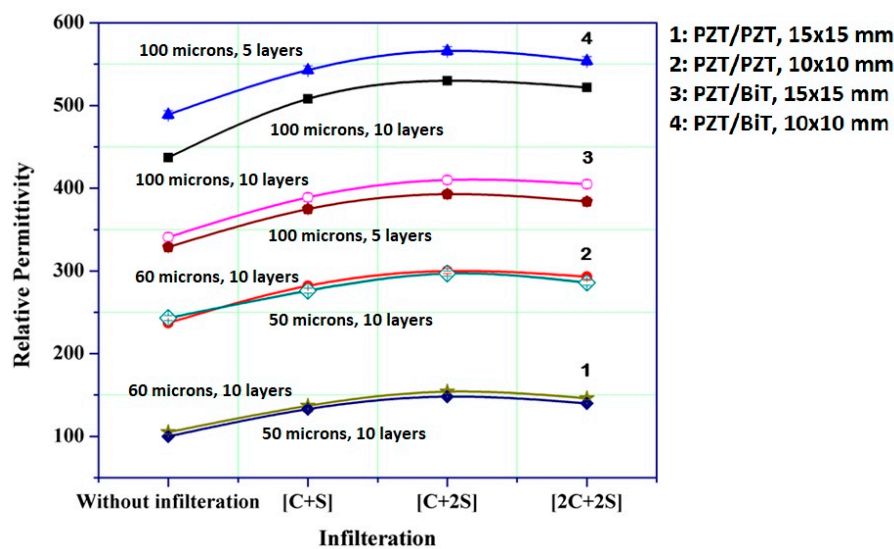


Figure 10. Variation of dielectric permittivity in piezoelectric composite films of  $[k_1C+k_2S]$  structure.

The same goes true over the blades of type S such that the S<sub>6</sub>-PZT/BiT films show higher permittivity than S<sub>5</sub>-PZT/PZT films. Except for porosity, another effective parameter on the characteristics of the thick composite films is the volumetric ratio of PZT powder to the sol-gel solution.

#### 4.7 Remnant Polarization ( $P_r$ )

The remnant polarization ( $P$  at electric field=0), similar to the dielectric permittivity, is raised by increasing the number of sol-gel infiltration through the composite layers. The films of larger dimensions have more desirable conditions in terms of internal tension and uniform heat absorption, hence their remnant polarization is a little higher. The results indicate a higher remnant polarization in L-PZT/BiT films compared to the L-PZT/PZT samples. The reason could be attributed to several factors including, the better penetration of BiT solution compared to PZT through the composite layers of the thick films, the relative decline in the porosity, higher viscosity of BiT solution that facilitates the deposition of thicker films up to 100 microns in this research. The thicker the films the greater number of grains will be formed in the microstructure and the remnant polarization will increase, proportionally. The  $P$ - $E$  hysteresis loops of a two samples are displayed in Figure 11. This figure also represents the input (feed) and the amplified output (measured) voltage signals on the

oscilloscope during the  $P$ - $E$  hysteresis loop measurement at 50 Hz. Equation 1 shows how the polarization ( $P$ ) is derived from current ( $I$ ), electric displacement ( $D$ ), electric charge ( $Q=I/t$ ), time ( $t$ ), cross-section ( $A$ ), and electric field ( $E$ ). The Matlab coding program for calculation of the  $P$ - $E$  hysteresis loop is presented in Appendix A, which is based on the standard IEEE180, National Physics Laboratory, UK [39].

$$D = \frac{Q}{A} = \epsilon E + P, \quad (1)$$

#### 4.8 Piezoelectric charge/strain coefficients

The piezoelectric strain coefficients ( $d_{31}$ ,  $d_{33}$ ) are also a function of the thickness (number of layers), the number of sol-gel infiltration, and the film porosity. The characterization results of piezoelectric films over the S and L films, represented in Table 3, show that thicker films have greater piezoelectric coefficients due to the larger grain sizes, the fewer grain boundaries, less spinning lock on the boundaries, and more freedom of movement on the non-180° domain walls. The larger cross-section has led to more porosity and defeats inside the film and electrode and finally a drop in piezoelectric coefficient.

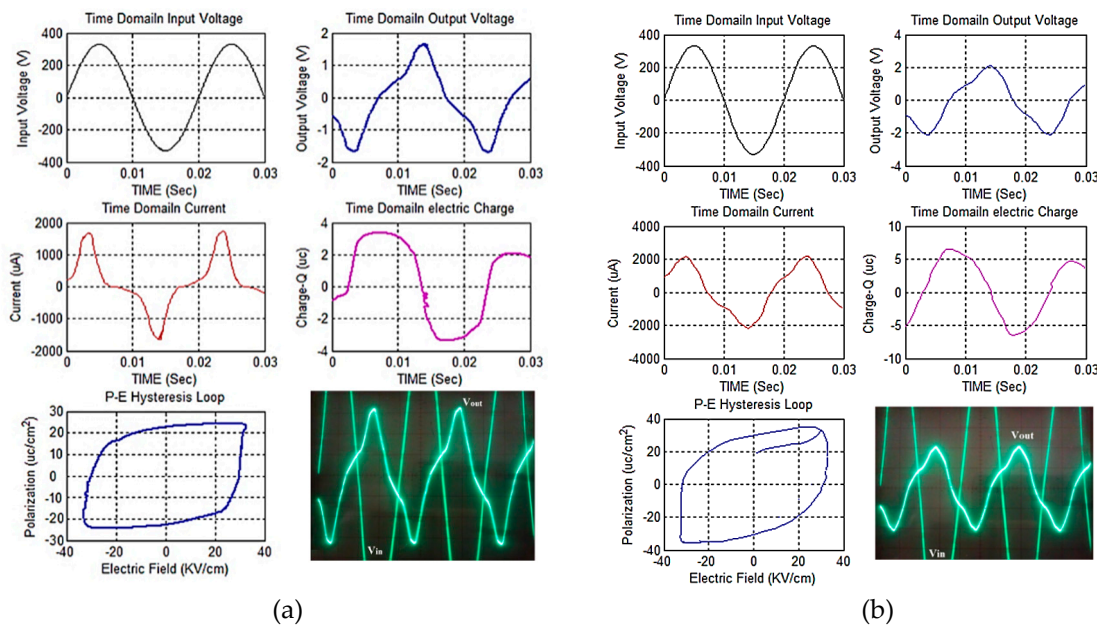


Figure 11.  $P$ - $E$  hysteresis loop for the composite piezo-films: a) L1-A and b) L1-B.

## 5. Conclusions

PZT/PZT and PZT/BiT composite piezo-sensors were derived in this research from sol-gel-based photochemical metal organic and infiltration technique. Characterization showed promising results in deposition of thick intelligent sensors on the curved surface of heavy superalloy blades, as an example of aerospace or power plant structures working at relatively high speeds and temperatures, with irregular shapes not being able to undergo typical spin coating. The optical microscopic images showed that the penetration of the sol-gel solution into the composite layers has been quite effective resulting a crack-free and smooth surface; thus reduced the porosity, agglomeration, and strengthened the cohesion of the films, which led to a remarkable growth in micro-hardness. The results also expressed the Curie temperature of PZT/PZT samples nearly equal to 300–320 °C, and that of PZT/BiT samples around 370–380 °C, which demonstrates the operational temperature range of such sensors once deposited on jet engine compressor blades as discussed in our previously published paper. Moreover, the sol-gel infiltration showed a great contribution to the improvement of surface roughness, micro-structural, dielectric ( $C$ - $V$ ), ferroelectric ( $P$ - $E$ ) and piezoelectric properties

of the deposited films. The sensor dimension, number of layers and porosity exhibited significant impacts on the relative dielectric constant. The dielectric permittivity of PZT/PZT films was observed less than that of PZT/BiT ones; the difference may come from a better penetration of thinner BiT sol-gel solution, which helps consequently obtain less porosity. Similar to the dielectric permittivity, the remnant polarization rose by increasing the number of sol-gel infiltration through the composite layers. The results also depicted a higher remnant polarization in L-PZT/BiT films in comparison with the S-PZT/PZT samples. Similar to the dielectric permittivity and remnant polarization, the piezoelectric strain coefficients had direct relationship with the thickness, the number of sol-gel infiltration and the film porosity; therefore, the thicker films showed higher piezoelectric coefficients.

**Author Contributions:** conceptualization, H.H. and P.H.; methodology, H.H., P.H., and H.H.P.; software, H.H.; validation, H.H., and H.H.P.; formal analysis, H.H.; investigation, H.H.; resources, H.H.P. and H.H.; data curation, H.H.; project administration, H.H. and H.H.P.; writing—original draft preparation, H.H., N.E., A.J. and P.H.; writing—review and editing, H.H., N.E., A.J. and H.H.P.; visualization, H.H.; supervision, H.H. and H.H.P.; funding acquisition, H.H. and H.H.P.;

**Funding:** This research was supported by Creative Materials Discovery Program through the National Research Foundation of Korea (NRF) funded by Ministry of Science and ICT (2018M3D1A1058536). This work was supported by 'Korea-Africa Joint Research Programme' grant funded by the Korea government (Ministry of Science, Technology & ICT) in 2017K1A3A1A09085891. This work was supported (researched) by the third stage of Brain Korea 21 Plus Project in 2018.

**Acknowledgments:** The authors express their thanks to the Material Characterization Lab (MCLAB) at Yonsei University, South Korea, where the generous scientists/engineers provided us with a favorable research environment as well as all required tools, devices, and instruments.

**Conflicts of Interest:** The authors declare no conflict of interest.

## Appendix A

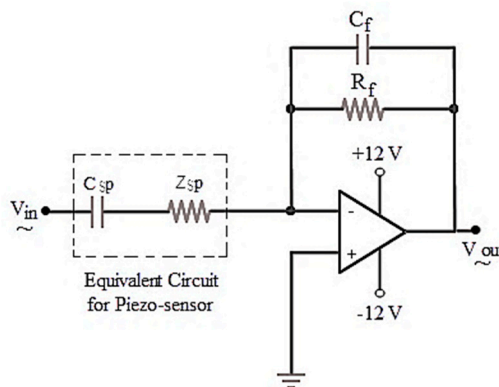


Figure A-8. Current to voltage converter circuit for the piezoelectric films undergone the *P-E* hysteresis loop measurement [40].

% Hysteresis Measurement with a RC Circuit at feedback

%  $C_{sp}=24.6$  nF,  $R_f=1.83$  Mohm,  $C_f=33$  nF;

$f=50$ ;  $T=1/f$ ;

% Frequency/ Period

$w=2*\pi*f$ ;

% Input Voltage ( $V_{in}$  applied by the function generator);

prompt= {' $V_{in}$  Amplitude (volts)', ' $V_{out}$  Amplitude (volts)', 'Phase Difference (ms)', 'Feedback Resistance... (Ohm)', 'Feedback Capacitance (Farad)', 'Sensor Area (mm<sup>2</sup>)', 'Film Thickness (mm)'};

defaultanswer={'10','10','1.83e6','33e-9','314.159','0.2'};

del=inputdlg(prompt,'Input',1, defaultanswer);

$V_{in\_amp}=\text{str2num}(\text{del}\{1,:})$

% Amplified feed voltage

$V_{out\_amp}=\text{str2num}(\text{del}\{2,:})$

% Output measured voltage

$Ph\_dif=\text{str2num}(\text{del}\{3,:})$

% Phase difference



```

1  R=str2num(del{4,:}) % Feedback resistance
2  C=str2num(del{5,:}) % Feedback capacitance
3  A=str2num(del{6,:}) % Piezo-film area
4  thickness=str2num(del{7,:}) % Film thickness
5  time=0:(T/100):T; % Time series from digitized data
6  phase1= -pi/2;
7  Vin=Vin_amp*cos((2* pi *f* time)+phase1); % Vin vector considering phase difference
8  subplot (3,2,1)
9  plot(time,Vin,'k');
10 xlabel('TIME (sec)'); % Adding axis labels and plot title
11 ylabel('Input Voltage (V)');
12 title('Time Domain Input Voltage');
13 grid on;
14
15 % Output Voltage (Vout measured by the oscilloscope);
16 Ph_rad=Ph_dif*2*pi/(T*1000); % Convert to Radiant
17 phase_abs=(-Ph_rad+ pi/2); % Phase difference between Vin and Vout
18 Vout=Vout_amp*exp(-1i*phase_abs)*exp(1i*w*time);
19 subplot (3,2,2)
20 plot(time,Vout,'b');
21 xlabel('TIME (sec)'); % Add axis labels and plot title
22 ylabel('Output Voltage (V)');
23 title('Time Domain Output Voltage');... (Continued the same as previous)
24 Xc=1/(1i*C*f*w); % Capacitor impedance
25 Zf=Rf*Xc/(Rf+Xc); % Feedback Impedance
26 Zf_amp=sqrt(((real(Zf))^2)+(imag(Zf))^2);
27 Zf_phase=atan((imag(Zf))/(real(Zf)));
28 I_phase=exp(1i*phase_abs)/exp(1i*Zf_phase) % micro-ampere
29 current=(1e6)*(Vout_amp/Zf_amp)*(cos((w*time)+I_phase));
30 subplot(3,2,3)
31 plot(time, current, 'r');

```

## 32 References

- 33 1. Pérez de la Cruz, J. Piezoelectric Thick Films: Preparation and characterization. In *Microelectromechanical*
- 34 *Systems and Devices*, Islam, N. Ed.; InTech: USA, 2012; pp. 1557–2542, ISBN: 978-953-51-0306-6.
- 35 2. Giurgiutiu, V. Piezoelectric Wafer Active Sensors – PWAS Transducers. In *Structural Health Monitoring with*
- 36 *Piezoelectric Wafer Active Sensors*, 2nd ed.; Academic Press: USA, 2014; pp. 357–394, ISBN: 0124201024,
- 37 9780124201026.
- 38 3. Hoshyarmanesh, H.; Abbasi, A. Structural health monitoring of rotary aerospace structures based on
- 39 electromechanical impedance of integrated piezoelectric transducers. *J. Intell. Mater. Syst. Struct.* **2018**, *29*,
- 40 1799–1817, <https://doi.org/10.1177/1045389X17754266>.
- 41 4. Hoshyarmanesh, H.; Maddahi, Y. Poling process of composite piezoelectric sensors for structural health
- 42 monitoring: a pilot comparative study. *IEEE Sens. Lett.* **2018**, *2*, 1–4, DOI: 10.1109/LENS.2018.2806301.
- 43 5. Hoshyarmanesh, H.; Abbasi, A.; Moein, P.; Ghodsi, M.; Zareinia, K. Design and Implementation of an
- 44 Accurate, Portable, and Time-Efficient Impedance-Based Transceiver for Structural Health Monitoring.
- 45 *IEEE/ASME Trans. Mechat.* **2017**, *22*, 2809 - 2814, DOI: 10.1109/TMECH.2017.2761902.
- 46 6. Hoshyarmanesh, H.; Ghodsi, M.; Park, H.H. Electrical properties of UV-irradiated thick film piezo-sensors
- 47 on superalloy IN718 using photochemical metal organic deposition. *Thin Solid Film* **2016**, *616*, 673–679,
- 48 <https://doi.org/10.1016/j.tsf.2016.08.009>.
- 49 7. Hoshyarmanesh, H.; Nehzat, N.; Salehi, M.; Ghodsi, M.; Lee, H.S.; Park, H.H. Thickness and thermal
- 50 processing contribution on piezoelectric characteristics of Pb(Zr-Ti)O<sub>3</sub> thick films deposited on curved
- 51 IN738 using sol-gel technique. *J. Mater: Design and Applications* **2015**, *229*, 511-521, [https://doi.org/](https://doi.org/10.1177/1464420714568787)
- 52 10.1177/1464420714568787.

8. Tsurumi, T.; Ozawa, S.; Abe, G.; Ohashi, N.; Wada, S.; Yamane, M. Preparation of  $\text{Pb}(\text{Zr}_{0.53}\text{Ti}_{0.47})\text{O}_3$  thick films by an interfacial polymerization method on silicon substrates and their electric and piezoelectric properties. *Jpn. J. Appl. Phys.* **2000**, *39*, 5604, <https://doi.org/10.1143/JJAP.39.5604>.
9. Bernstein, J.J.; Finberg, S.L.; Houston, K.; Niles, L.C.; Chen, H.D.; Cross, L.E.; Li, K.K. Micromachined high frequency ferroelectric sonar transducers. *IEEE Trans. Ultrason. Ferroelectr. Freq. Control.* **1997**, *44*, 960–969, DOI: 10.1109/58.655620.
10. Akasheh, F.; Myers, T.; Fraser, J.D.; Bose, S.; Bandyopadhyay, A. Development of piezoelectric micromachined ultrasonic transducers. *Sens. Actuators Phys.* **2004**, *111*, 275–287, <https://doi.org/10.1016/j.sna.2003.11.022>.
11. de Cicco, G.; Morten, B.; Prudenziati, M. Elastic surface wave devices based on piezoelectric thick-films. *IEEE Trans. Ultrason. Ferroelectr. Freq. Control* **1996**, *43*, 73–77, DOI: 10.1109/58.484466.
12. Chan, H.L.W.; Lau, S.T.; Kwok, K.W.; Zhang, Q.Q.; Zhou, Q.F.; Choy, C.L. Nanocomposite ultrasonic hydrophones. *Sens. Actuators Phys.* **1999**, *75*, 252–256, [https://doi.org/10.1016/S0924-4247\(99\)00076-X](https://doi.org/10.1016/S0924-4247(99)00076-X).
13. Xia, D.; Liu, M.; Zeng, Y.; Li, C. Fabrication and electrical properties of lead zirconate titanate thick films by the new sol–gel method. *Mater. Sci. Eng. B* **2001**, *87*, 160–163, [https://doi.org/10.1016/S0921-5107\(01\)00704-8](https://doi.org/10.1016/S0921-5107(01)00704-8).
14. Ledermann, N.; Mural, P.; Baborowski, J.; Gentil, S.; Mukati, K.; Cantoni, M.; Seifert, A.; Setter, N. {1 0 0}-Textured, piezoelectric  $\text{Pb}(\text{Zr}_x\text{Ti}_{1-x})\text{O}_3$  thin films for MEMS: integration, deposition and properties. *Sens. Actuators Phys.* **2003**, *105*, 162–170, [https://doi.org/10.1016/S0924-4247\(03\)00090-6](https://doi.org/10.1016/S0924-4247(03)00090-6).
15. Yang, C.; Liu, J.; Zhang, S.; Chen, Z. Characterization of  $\text{Pb}(\text{Zr,Ti})\text{O}_3$  thin film prepared by pulsed laser deposition. *Mater. Sci. Eng. B* **2003**, *99*, 356–359, <https://doi.org/10.1080/00150199908015767>.
16. Priya, S.; Ryu, J.; Park, C.S.; Oliver, J.; Choi, J.J.; Park, D.S. Piezoelectric and magnetoelectric thick films for fabricating power sources in wireless sensor nodes. *Sensors* **2009**, *9*, 6362–6384, DOI: 10.3390/s90806362.
17. Walter, V.; Delobelle, P.; Moal, P.L.; Joseph, E.; Collet, M. A piezo-mechanical characterization of PZT thick films screen-printed on alumina substrate. *Sens. Actuators Phys.* **2002**, *96*, 157–166, [https://doi.org/10.1016/S0924-4247\(01\)00767-1](https://doi.org/10.1016/S0924-4247(01)00767-1).
18. Kobayashi, M.; Olding, T.; Sayer, M.; Jen, C.K. Piezoelectric thick film ultrasonic transducers fabricated by sol-gel spray technique. *Ultrasonics* **2002**, *39*, 675–680, [https://doi.org/10.1016/S0041-624X\(02\)00390-6](https://doi.org/10.1016/S0041-624X(02)00390-6).
19. Pérez de la Cruz J.; Vyshatko, N.P.; Vilarinho, P.M.; Kholkin, A.L. Electrical properties of lead zirconate titanate thick films prepared by hybrid sol-gel method with multiple infiltration steps. *Materials Chemistry and Physics* **2007**, *101*, 280–284, <https://doi.org/10.1016/j.matchemphys.2006.05.003>.
20. He, X.Y.; Ding, A.L.; Zheng, X.S.; Qiu, P.S.; Luo, W.G. Preparation of PZT(53/47) thick films deposited by a dip-coating process. *Microelectron. Eng.* **2003**, *66*, 865–871, [https://doi.org/10.1016/S0167-9317\(02\)01013-4](https://doi.org/10.1016/S0167-9317(02)01013-4).
21. Zhou, Q.F.; Chan, H.L.W.; Choy, C.L. PZT ceramic/ceramic 0–3 nanocomposite films for ultrasonic transducer applications. *Thin Solid Films* **2000**, *375*, 95–99, [https://doi.org/10.1016/S0040-6090\(00\)01232-3](https://doi.org/10.1016/S0040-6090(00)01232-3).
22. Shelton, C.T. Development of perovskite thin films for use in piezoelectric based microelectromechanical systems. *Master of Science Thesis in Materials Science*, Oregon State University, USA, Sep. 2009.
23. Kholkin, A.L.; Yarmarkin, V.K.; Wu, A.; Avdeev, M.; Vilarinho, P.M.; Baptista, J.L. PZT-based piezoelectric composites via a modified sol–gel route. *J. Eur. Ceram. Soc.* **2001**, *21*, 1535–1538, [https://doi.org/10.1016/S0955-2219\(01\)00058-9](https://doi.org/10.1016/S0955-2219(01)00058-9).
24. Barrow, D.A.; Petroff, T.E.; Sayer, M. Thick ceramic coatings using a sol gel based ceramic-ceramic 0–3 composite. *Surf. Coat. Technol.* **1995**, *76–77*, 113–118, [https://doi.org/10.1016/0257-8972\(95\)02562-6](https://doi.org/10.1016/0257-8972(95)02562-6).
25. Wu, A.; Vilarinho, P.M.; Salvado, I.M.M.; Baptista, J.L.; de Jesus, C.M.; da Silva, M.F. Characterization of seeded sol–gel lead zirconate titanate thin films. *J. Eur. Ceram. Soc.* **1999**, *19*, 1403–1407, [https://doi.org/10.1016/S0955-2219\(98\)00445-2](https://doi.org/10.1016/S0955-2219(98)00445-2).
26. Erturk, A.; Inman, D.J. *Piezoelectric Energy Harvesting*, 1st ed.; Wiley: West Sussex, UK, 2011, ISBN 9780470682548.
27. IEEE ultrasonics and frequency control society. standards committee and American national standards institute., *IEEE standard on piezoelectricity*. New York: Institute of Electrical and Electronics Engineers, 1988.
28. Heinonen, E.; Juuti, J.; Leppävuori, S. Characterization and modelling of 3D piezoelectric ceramic structures with ATILA software. *J. Eur. Ceram. Soc.* **2005**, *25*, 2467–2470, <https://doi.org/10.1016/j.jeurceramsoc.2005.03.083>.
29. Na, S.; Lee, H.K. A technique for electro-mechanical impedance method on peak free frequency domain. 6<sup>th</sup> Int. Workshop on Advanced Smart Materials and Smart Structures Technology, Dalian, China, 2011.

- 1 30. Charlesworth, J. P.; Temple, J.A.G. *Engineering Applications of ultrasonic time-of-flight diffraction*  
2 (ultrasonic inspection in engineering series), 2<sup>nd</sup> ed.; Research Studies Press: Hertfordshire, England, 2001,  
3 ISBN: 0863802397.
- 4 31. Pérez de la Cruz, J. Preparation and characterization of ferroelectric PZT films for electromechanical and  
5 memory applications. Doctoral thesis, University of Aveiro, Portugal, 2004.
- 6 32. Hoshyarmanesh, H.; Nehzat, N.; Salehi, M.; Ghodsi, M.; Lee, H.S.; Park, H.H. Piezoelectric transducers on  
7 curved dispersive bending wave and poke-charged touch screens. *J. Mater. Manuf. Proc.* **2014**, *29*, 870–  
8 876, <https://doi.org/10.1080/10426914.2014.921710>.
- 9 33. Pérez de la Cruz, J.; Joanni, E.; Vilarinho, P.M.; Kholkin, A.L. Thickness effect on the dielectric, ferroelectric,  
10 and piezoelectric properties of ferroelectric lead zirconate titanate thin films. *J. Appl. Physics* **2010**, *108*,  
11 114106, <https://doi.org/10.1063/1.3514170>.
- 12 34. Hindrichsen, C.C.; Pedersen, T.; Thomsen, E.V.; Hansen, K.; Lou-Møller, R. Investigation of top/bottom  
13 electrode and diffusion barrier layer for PZT thick film mems sensors. *Ferroelectrics* **2008**, *367*, 201–213,  
14 <https://doi.org/10.1080/00150190802375441>.
- 15 35. Rachakom, A.; Jiansirisomboon, S.; Watcharapasorn, A. Microstructures and mechanical properties of lead-  
16 free bismuth sodium titanate zirconate ceramics. *J Microscopy Soc. Thailand* **2009**, *23*, 107–110,
- 17 36. Sharma, P.K.; Ounaies, Z.; Varadan, V.V.; Varadan, V.K. Dielectric and piezoelectric properties of  
18 microwave sintered PZT. *Smart Mater. Struct.* **2001**, *10*, 878, <https://doi.org/10.1088/0964-1726/10/5/304>.
- 19 37. Garg, A.; Goel, T.C. Mechanical and electrical properties of PZT ceramics (Zr:Ti=0.40:0.60) related to Nd3+  
20 Addition. *Mater. Sci. Eng. B* **1999**, *60*, 128–132, [https://doi.org/10.1016/S0921-5107\(99\)00072-0](https://doi.org/10.1016/S0921-5107(99)00072-0).
- 21 38. Dorey, R.A.; Stringfellow, S.B.; Whatmore, R.W. Effect of sintering aid and repeated sintering on the  
22 dielectric and piezoelectric properties of a PZT composite thick film. *J. Eur. Ceram. Soc.* **2002**, *22*, 2921–2926,  
23 DOI: 1016/S0955-2219(02)00062-6.
- 24 39. Stewart, M.; Cain, M.G. Ferroelectric hysteresis measurement & analysis. *NPL Report CMMT(A) 152*,  
25 National Physical Laboratory, University of Manchester, 1999.
- 26 40. Texas Instruments, *LM741 Operational Amplifier*. 2014, ([www.ti.com](http://www.ti.com)).